

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:		)	
		)	
Hirofu	mi MIYAJIMA et al.	)	Confirmation No.: 3310
Application No.: 09/773,509		)	Group Art Unit: 2828
Applic	adion No.: 09///3,309	) }	Group Art Omt. 2020
Filed:	February 2, 2001	)	Examiner: C. H. Jackson
	•	)	
For:	HEAT SINK AND SEMICONDUCTOR LASER	)	
	APPARATUS AND SEMICONDUCTOR LASER	)	
	STACK APPARATUS USING THE SAME	)	

Commissioner for Patents
U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Sir:

## PETITION FOR EXTENSION OF TIME UNDER 37 CFR § 1.136(a)

It is respectfully requested that the time for response to the Office Action dated December 30, 2003 be extended for a period of two (2) months from March 30, 2004 to and including May 30, 2004.

The fee for this extension is estimated to be \$310.00 (an extension of time was filed on April 28, 2004 and \$110 was paid at that time). Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310. A copy of this sheet is enclosed.

Respectfully submitted,

MORGAN, LEWIS & BOCKIUS LLP

Dated: May 28, 2004

Kent Basson

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